MOPB102



Comments on Electropolishing at Ettore Zanon SpA at the end of EXFEL production



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EP FACILITY

INTRODUCTION

In 2013 a new horizontal Electropolishing facility was developed and implemented by Ettore Zanon SpA

More than 300 cavities have been treated by electropolishing for the preparation of cavities for EXFEL series production at EZ. Electro polishing was in use there for two major applications: bulk removal during series production and recovering of cavities with surface defects. For the LCLSII project the EP system will be updated.



The facility can perform five bulk treatments

EP TREATMENT

BCP flash production scheme for EXFEL: 140 µm EP as first cleaning + 10 µm BCP after He tank integration

A typical main EP for a EXFEL cavity (total removal: 145µm).

Main Paramenters for EXFEL:

- Voltage : **17** V
- Average current value: **≈270** A
- Average acid temperature value: ≈ 32 °C
- Acid flowrate: **10 l/min**
- Automatic current and temperature control
- Automatic movements and rotation
- Sensors for: temperature, pressure, flowrate, acid level
- Personnel and explosion safety \rightarrow H₂ and **HF** control
- Removal rate: $\approx 0.4 \,\mu\text{m/min}$
- Main EP completed in 6 hours



A one/two days maintenance every month is necessary to assure stable quality.







A typical EP

RESULTS AND CONCLUSIONS



The material removed by EP causes a frequency

variation in the cavity.

Correlation depends on:

- differential removal iris/equator
- EP facility and parameters.

Data are quite scattered, but:

- mean value used for cavity composition: $1 \mu m \approx 6 \text{ kHz}$
- specification requirements fulfilled.

According to Desy request, several cavities did a longer EP to verify if a higher surface removal could improve **Eacc performances**. Data collected from 300 cavities show no

The completion of EXFEL production has shown that the facility is reliable. More investigation may be interesting to understand frequency variation behavior. As long as the minimum 140 µm removal is guaranteed, cavities electropolished with this facility perform well during vertical test, above requested goal (23 MV/m). Facing the new production of cavities for the upgrading of LCLSII, the process will be modified and verified according to specification of Jefferson Lab.

correlation.

